

Nanoparticles and nanocomposites for display applications

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Abstract

The optical response of metallic structures has attracted significant interest for various applications in recent years. Of particular relevance to display applications is the ability to optimize the intensity and wavelength of the radiation which is scattered by the structure. In this thesis, original studies are presented across three main sections which investigate the optical response of a variety of composite structures formed from metal and dielectric elements.

In the first section, the optical response of planar structures comprised of continuous metal and dielectric layers is discussed. An extensive study is conducted into the transmission pass-band characteristics exhibited by these structures, in particular the dependence on parameters such as metal layer thickness, layer spacing and the number of periods.

The second and third sections include examples of structures in which the metallic elements are non-continuous. The simulations required here are considerably more involved, and so an introduction is given to the computational techniques used in subsequent chapters, accompanied with results for a test structure. The structures in the second section include single metallic nanoparticles and particle pairs which exhibit localised surface plasmon resonances (LSPRs). It is also shown that when particles are arranged into periodic arrays, the properties of the LSPR may be significantly modified by long-range and short-range interactions. This has implications both in terms of the line shape of the optical response, and the sensitivity of the optical response to changes in the surrounding refractive index.

The third section includes an investigation into metallic layers which have been perforated with periodic arrangements of holes. These structures have attracted considerable attention in recent years due to the enhanced transmission which is observed when the periodicity of the hole array facilitates grating coupling to surface plasmon-polariton (SPP) modes associated with the metal film. It is shown that these structures also support localised resonances similar to those of metallic nanoparticles. A comparison is made between the LSPRs observed in metallic nanoparticle and nanohole arrays for which the periodicity is non-diffracting for frequencies in the vicinity of LSPRs. In the final part of the thesis the role of LSPRs in facilitating a negative index of refraction in electromagnetic metamaterials having a fishnet-type structure is investigated.

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Table of contents

Abstract	1
Acknowledgements	2-3
Table of Contents	4-6
List of Tables and Figures	7-18
Chapter 1 – Introduction	19-23
1.1 Aim of Research	19
1.2 Outline of Thesis	21
Chapter 2 – The optical response of continuous metal-dielectric multilayer structures exhibiting Fabry-Perot transmission resonances	24-53
2.1 Introduction	24
2.2 Simulating the optical response of metal-dielectric multilayer structures	25
2.3 A review of previous studies involving multilayer structures	26
2.4 Experimental studies of single cavity structures (Ag-MgF ₂ -Ag)	30
2.5 Multiple cavity structures (Ag-MgF ₂ -Ag-MgF ₂)	34
2.6 Analogy with the classical example of masses coupled by springs	41
2.7 Transmittance enhancement through multiple cavity structures	42
2.8 Studies of Fabry-Perot transmission resonances at microwave frequencies	47
2.9 Concluding remarks	52
Chapter 3 – Techniques used to simulate the scattering of electromagnetic radiation from metallic nanoparticle and nanohole structures	54-81
3.1 Introduction	54
3.2 Mie Theory	54
3.3 The ‘T Matrix’ method	63
3.4 The Discrete Dipole Approximation (DDA)	64
3.5 The Finite Element method	65
3.6 The Finite Difference Time Domain method	69
3.7 Example scattering calculations for an 80 nm diameter Au sphere	70
3.8 Summary of results and concluding remarks	79
Chapter 4 – The scattering of electromagnetic radiation from metallic nanoparticles	82-122
4.1 Introduction	82
4.2 Fabrication using EBL and FIB techniques	83
4.3 The electromagnetic response of small metallic particles	86
4.4 Optical characterisation using dark-field spectroscopy	95
4.5 Excitation of higher-order LSPR modes	100
4.6 Arrangements of nanorods	110
4.7 Concluding remarks and summary of results	120

Chapter 5 – The optical response of metallic nanoparticles arranged in periodic arrays	123-150
5.1 Introduction	123
5.2 Modification of the single particle response in regular arrays	124
5.3 The effects of particle size variation	133
5.4 Refractive index sensitivity of nanoparticle arrays	136
5.5 Interparticle coupling and variations in the array period	142
5.6 Concluding remarks	149
Chapter 6 – The optical response of nanometric films perforated with subwavelength holes	151-170
6.1 Introduction	151
6.2 Enhanced transmission through optically thick perforated metal films	152
6.3 Localised resonances of holes in optically thin metal films	157
6.4 Studies of complementary metallic nanoparticle and nanohole arrays	159
6.5 Interhole coupling and variations in the array period	161
6.6 Effects of hole size and geometrical variations	165
6.7 Possible applications	168
6.8 Concluding remarks	169
Chapter 7 – Interactions between Fabry-Perot and nanohole resonances	171-188
7.1 Introduction	171
7.2 Optical response of a perforated metallic layer	172
7.3 Fabry-Perot resonances in metal-dielectric multilayer structures	173
7.4 Interactions between LSPRs and FP modes in perforated structures	175
7.5 Effects of hole diameter variation	179
7.6 Effects of metallic dispersion	181
7.7 Increasing the number of periods within the multilayer structure	184
7.8 Tunability of the interaction between LSPR/FP modes	186
7.9 Summary of results and concluding remarks	188
Chapter 8 – The role of localised resonances in negative index metamaterials	189-213
8.1 Introduction	189
8.2 The concept of a perfect lens, and negative refraction in perfect lensing applications	190
8.3 The response of a composite structure formed from metallic wires and split rings	192
8.4 Negative index response of fishnet-type metamaterial structures	197
8.5 Extraction of effective parameters	200
8.6 Localised resonances in fishnet-type metamaterials	205
8.7 Coupled LSPRs in stacked metallic nanohole and nanoparticle structures	207
8.8 Concluding remarks	213

Chapter 9 – Conclusions and future work	214-220
9.1 Summary	214
9.2 Possible applications	216
9.3 Future work	218
9.4 Publications	219
9.5 Disclosure	219
9.6 Conference presentations	219
APPENDIX A – Multilayer optics	221-226
A.1 Transmission and reflection at a single interface	221
A.2 The recursive Fresnel method	225
APPENDIX B- Legendre polynomials and the solution of 2nd order ODE's	227-229
APPENDIX C - The generation of solutions to Bessel's equation	230-234
APPENDIX D - Fabrication of samples using a thermal evaporation technique	235-241
D.1 Introduction	235
D.2 Experimental apparatus	235
D.3 Overview of operation	240
List of References	242-249

List of Figures and Tables

Figure 2.1: The transmission and reflection of light in an arrangement formed from N isotropic layers.

Figure 2.2: The simulated transmittance spectrum¹⁰ is shown for a multilayer structure comprised of 2.5 periods of 38 nm Ag and 233 nm MgF₂. The structure is illuminated at normal incidence in air.

Figure 2.3 *reproduced from reference 13:* A Gaussian wave packet (TM polarisation) with carrier wavelength 400 nm is incident at 45 degrees on an Ag-MgF₂ stack. The figure shows several snapshots of magnetic field intensity. The centre of the output pulse is shifted upwards by approximately 266 nm.

Figure 2.4 *reproduced from reference 13:* A TM-polarized beam or pulse is incident from vacuum onto a metal layer at frequencies below the plasma frequency where the real part of the dielectric constant is negative. The preservation of the continuity of the normal component of the electric displacement vector (**D**) leads to a sign change in the E_z field component when the dielectric constants have opposite signs.

Figure 2.5: Experimental and simulated transmittance spectra for a structure consisting of 1.5 periods of 20 nm Ag / 140 nm MgF₂ on a silica slide ($n_r = 1.46$, $n_i = 0.00$), illuminated at normal incidence in air. The dashed line shows the simulated transmittance of a single 40 nm Ag film. Inset (a) shows a colour photograph of the structure viewed in transmission when illuminated with a diffuse white light source (the image has been normalised to the lamp spectrum), and inset (b) shows a schematic of the layering arrangement.

Figure 2.6: The time-averaged electric field intensity is shown for a cross section taken perpendicular to the 20 nm Ag / 140 nm MgF₂ / 20 nm Ag stack at an incident wavelength of 560 nm.

Figure 2.7: Simulated and experimental transmittance spectra are shown for two 20 nm Ag layers separated by 140, 180 and 200 nm of MgF₂. The structure is on a silica slide ($n_r = 1.46$, $n_i = 0.00$) and is illuminated at normal incidence in air. The inset shows colour photographs of the structures viewed in transmission when illuminated with a diffuse white light source (normalised for the lamp spectrum).

Figure 2.8: Simulated transmittance and absorbance spectra for a structure consisting of 4.5 periods of 20 nm Ag / 110 nm MgF₂. The structure is illuminated at normal incidence and is surrounded by glass ($n_r = 1.52$, $n_i = 0.00$).

Figure 2.9: The time-averaged electric field magnitude is plotted for a cross section taken perpendicular to the multilayer stack at the resonant wavelengths marked A-D in Figure 2.8.

Figure 2.10: Simulated transmission and absorbance spectrum of a structure consisting of 10.5 periods of 20 nm Ag / 110 nm MgF₂. The structure is illuminated at normal incidence and is surrounded by glass $n_r = 1.52$, $n_i = 0.00$.

Figure 2.11: The high frequency band edge of a multilayer structure formed from a periodic arrangement of Ag and MgF₂ is solved numerically in terms of k_0 .

Figure 2.12: The low frequency band edge of a multilayer structure formed from a periodic arrangement of Ag and MgF₂ is solved numerically in terms of k_0 .

Figure 2.13: A one-dimensional classical analogy of two weakly coupled oscillators.

Figure 2.14: Simulated transmittance (i), absorbance (ii) and reflectance (iii) spectra for 50 layers of Ag with thickness 5 nm (A), 25 layers of Ag with thickness 10 nm (B), 10 layers of Ag with thickness 25 nm (C) and 5 layers of Ag with thickness 50 nm (D), each separated by 110 nm of MgF₂. The dashed line is the response of a single layer of 250 nm Ag. The structure is illuminated at normal incidence and is surrounded by glass ($n_r = 1.52$, $n_i = 0.00$).

Figure 2.15: A diagram showing the electric field distribution for a section (metal-air-metal) of a multilayer structure at the low frequency band edge, where the metal layers have thickness (a) 20 nm and (b) 10 nm.

Figure 2.16: Time-averaged electric field profiles at the high frequency band edge for the multilayer structures in Figure 2.14 consisting of 5 nm (A), 10 nm (B), 25 nm (C) and 50 nm (D) thick Ag layers separated by 110 nm of MgF₂. The structure is illuminated at normal incidence and is surrounded by glass ($n_r = 1.52$, $n_i = 0.00$).

Figure 2.17: The simulated transmittance and reflectance spectra are shown for two layers of 20 nm thick Ag ($\epsilon = -10^4 + 10^7i$) separated by 10 nm of vacuum. The sample is illuminated at normal incidence with frequencies ranging from 30 – 60 GHz ($3.0 - 6.0 \times 10^{10}$ Hz).

Figure 2.18 reproduced from reference 29 (Butler et al.) : Experimental transmission spectrum of a metamaterial comprising a stack of metallic grid and dielectric layers at microwave frequencies with dielectric cavity thickness (t_d) 6.35 mm and metal layer thickness (t_m) 18 μ m. The inset shows the schematic of the structure and a plan view of the hole geometry, with parameters $\lambda_g = 5$ mm, $w_m = 0.15$ mm, $w_n = 4.85$ mm.

Figure 2.19 reproduced from reference 29 (Butler et al.): Instantaneous electric-field amplitude distributions as a function of distance perpendicular to the metallic grid-dielectric stack at each of the resonant frequencies marked A-D in Figure 2.18. The vertical dashed lines indicate the positions of the metallic grid layers.

Figure 3.1: The unit vectors of the spherical polar coordinate system are represented on Cartesian axes.

Figure 3.2: The scalar spherical harmonics are shown for $l = 1$ to 5 and $m = 1$ to l where θ is varied from 0 to 90° and ϕ is varied from 0 to 360°. The colour scale represents the magnitude of the product of the azimuthal and polar solutions to Equation 3.12, which have been normalised to the same scale (-1 to +1).

Figure 3.3: Electric field patterns (viewed in cross section) showing the normal modes of a sphere as proposed by Mie in 1908¹.

Figure 3.4: The Whitney tetrahedron – an example of a vector finite element.

Figure 3.5: The Cartesian grid configuration proposed by Yee in 1966.

Figure 3.6: The real and imaginary components of the permittivity are shown for Au for wavelengths in the range 400 – 750 nm. Permittivity values were obtained from reference data, published by Johnson & Christy³².

Figure 3.7: Q_{sca} plotted as a function of frequency for an 80 nm diameter Au sphere in vacuum, based upon simulated data obtained using Mie Theory (black), FDTD with an element length of 3.00 nm (red), T-Matrix (green), FEM with an element length of 3.11 nm (blue) and DDA with an interdipole spacing of 3.00 nm (cyan) methods. For the Mie Theory, T-Matrix, DDA and FEM simulation techniques the Au permittivity values were obtained from Johnson & Christy³². For the FDTD method a Drude model was used to calculate permittivity values ($\omega_p = 1.3 \times 10^{16} \text{ s}^{-1}$ and $\gamma = 5.0 \times 10^{13} \text{ s}^{-1}$).

Figure 3.8: Mie vs DDA: Q_{sca} simulated using Mie Theory for a 80 nm Au sphere in vacuum is directly compared with that obtained using the DDA method. The coloured data points show the effect of varying the inter-dipole spacing across a 2 nm to 5 nm range. *Inset* – relative error is plotted as a function of wavelength for different mesh sizes.

Figure 3.9: Mie vs FEM: Q_{sca} simulated using Mie Theory for a 80 nm Au sphere in vacuum is directly compared with that obtained using a FEM approach. The coloured data points show the effect of varying the mesh element length. *Inset* – relative error is plotted as a function of wavelength for different mesh sizes.

Figure 3.10: Q_{sca} simulated using Mie Theory for a 80 nm diameter Au sphere in vacuum is directly compared with that obtained using the FDTD method. A Drude model ($\omega_p = 1.3 \times 10^{16} \text{ s}^{-1}$ and $\gamma = 5.0 \times 10^{13} \text{ s}^{-1}$) is used to calculate Au permittivity values for both models. The coloured data points show the effect of varying mesh element length. *Inset* – relative error is plotted as a function of wavelength for different mesh sizes.

Table 3.1: Comparison of computation time, advantages and disadvantages of five commonly used computational techniques used to simulate light scattering from metallic nanoparticle and nanohole structures. Computations were performed on a Dell Vostro 200 personal computer, having a dual-core processor (each with a clock speed of 2.19 GHz), 2 Gb of RAM and 250 Gb of available hard drive space).

Figure 4.1: The main stages of an electron beam lithography process used to fabricate Au nanoparticles. The SEM image shows a single Au nanoparticle with diameter 90 nm and height 20 nm.

Figure 4.2: Spin speed curves for A2 (2%), A4 (4%) and A7 (7%) concentrations of PMMA dissolved in anisole.

Figure 4.3: Schematic representation of the material removal process. The inset shows SEM images of a cylindrical hole with 90 nm diameter and 20 nm depth and a square particle with 90 nm side length and 20 nm depth fabricated using FIB milling.

Figure 4.4: The real and imaginary components of the polarisability are plotted for a 60 nm diameter Ag sphere (left) in vacuum. This is compared against the scattering efficiency (Q_{sca}) which has been simulated using Mie Theory (right).

Figure 4.5: Schematic of an ellipsoidal particle, showing the axes of symmetry and the semi axis lengths a , b and c .

Figure 4.6: Using Equation 4.31, the shape factor L_a is plotted against the ratio of $a : (b,c)$ for an ellipsoid in which length a is fixed and lengths b,c are increased such that $b = c$.

Figure 4.7: The real and imaginary components of the polarisability are plotted as a function of wavelength for the incident electric field polarised parallel to the long and short axes of an Ag rod with dimensions $30 \text{ nm} \times 80 \text{ nm} \times 80 \text{ nm}$ (left). A T-Matrix method has been used to simulate the scattering efficiency of the rod illuminated with light polarised along the long and short axes (right).

Figure 4.8: An SEM image showing an example of cylindrical Au nanoparticles fabricated by EBL. These particles have height 35 nm and diameters ranging from 45 nm to 160 nm. *Note:* On the sample the particles are separated by $2 \mu\text{m}$ but the images have been merged for visualisation.

Figure 4.9: Schematic illustrating the experimental configuration for dark-field spectroscopy.

Figure 4.10: CCD image obtained from a dark field microscope used to observe scattering from Au discs with height 35 nm and diameters ranging from 45 nm to 160 nm. The image has been normalised to the lamp spectrum.

Figure 4.11: Dark field scattering spectra (a) of Au discs with height 35 nm and diameters ranging from 45 to 160 nm are compared with simulated spectra (b) obtained using a T-Matrix method. In (c) the resonant wavelengths and widths (d) from the experimental and simulated scattering spectra are compared.

Figure 4.12: Desired scattering response of a nanoparticle which could be hosted within a liquid crystal cell. In the diagram, θ represents the illumination angle of the incident beam which is polarized either parallel (E_{zy}) or perpendicular (E_x) to the plane of angular variation and ϕ represents the scattering angle of the radiated field.

Figure 4.13: The scattering efficiency of an Ag disc with height 25 nm and diameter 80 nm has been simulated using a T-Matrix method for light incident at various illumination angles θ ranging from 0 to 80 degrees. The incident beam is polarised parallel (a) and perpendicular (b) to the plane of angular variation. In the lower graph (c) the magnitude of the maxima from the scattering efficiency curves in (c) have been normalised to 1, and are plotted against a $\cos^2\theta$ function.

Figure 4.14: The scattered electric field distribution from the Ag disc has been simulated using a FEM technique and has been projected onto a spherical surface in the far field. A polar plot of the radiated field in the upper half space is shown for a cross section through the YZ plane. The electric field intensity has been plotted as a function of the scattering angle ϕ .

Figure 4.15: The instantaneous charge and field distributions are illustrated for two metallic nanoparticles which interact through the overlap of their resonant electromagnetic fields. Plasmon hybridisation can occur in particles separated by distances which are a few 10s of nm in vacuum, resulting in two coupled LSPRs associated with the anti-symmetric (a) and symmetric (b) distribution of charge across the structure.

Figure 4.16: The scattering efficiency of a 200 nm diameter Ag sphere in vacuum has been simulated using Mie Theory, with light incident at 45 degrees. A FEM technique has been

used to simulate the time-averaged electric field distributions for a cross section taken through the centre of the sphere at the resonant frequencies labelled A, B and C (intensity scales are arbitrary). The incident electric field is polarised along the direction shown by the arrow above the figures.

Figure 4.17: The scattered electric field distribution from a 200 nm diameter Ag sphere has been simulated using a FEM technique at the resonant frequency corresponding to the quadrupolar LSPR, and has been projected onto a spherical surface in the far field. A polar plot of the radiated field is shown on a polar plot as a function of the scattering angle ϕ for a cross section through the YZ plane.

Figure 4.18: The instantaneous field distribution is shown for a point dipole emitting a spherical wave (a), two point dipoles separated by $\lambda/2$ (along the y direction) emitting spherical waves which are out of phase by π radians (b), and (c) the sum of (a) and (b).

Figure 4.19: A FEM technique is used to simulate the optical response of an Ag nanorod in vacuum having dimensions length 80 nm, width 30 nm and height 25 nm respectively. The rod is illuminated in the configuration shown in (a). The angle of incidence θ is varied from 0 to 90 degrees in 15 degree increments, and the scattering efficiency is plotted as a function of wavelength in (b). In (c) the magnitude of the Q_{sca} maxima at 575 nm are plotted as a function of incident angle θ and are shown against a normalised $\cos^2\theta$ function.

Figure 4.20: Diagram showing three identical metallic rods separated by 20 nm in a linear chain, the resonant frequencies are shown below each rod. In the left of the figure, the direction of the incident wave vector and the polarisation of the incident electric field are shown.

Figure 4.21: Diagram showing three metallic rods separated by 20 nm in a linear arrangement, the resonant frequencies are shown below each rod. The outer rods have length L_1 and the centre rod has length L_2 . In the left of the figure, the direction of the incident wave vector and the polarisation direction of the incident electric field are shown.

Figure 4.22: A FEM technique is used to simulate the optical response of three Ag nanorods in vacuum. The central rod has length 60 nm, width 30 nm and height 25 nm. The upper and lower rods have length 80 nm, width 30 nm and height 25 nm. The rods are separated by 20 nm and are illuminated in the configuration shown in (a). The angle of incidence θ is varied from 0 to 90 degrees, and the scattering efficiency is plotted as a function of wavelength in (b). In (c) the magnitude of the Q_{sca} maxima at 615 nm are plotted as a function of incident angle and are shown against a normalised $\cos^2\theta$ function.

Figure 4.23: The time-averaged electric field distribution is shown for a cross section through the centre of the rods, which is shown for a plane lying perpendicular to the incident wave vector.

Figure 4.24: Several $\cos^n\theta$ functions are plotted as a function of θ , where n is varied from 2.0 to 6.0 and θ is varied from 0° to 90° .

Figure 4.25: The values of θ at $f(\theta) = 0.5$ (a) and the gradient of $f(\theta)$ at $f(\theta) = 0.5$ (b) are plotted as function of n.

Figure 4.26: In (a), the scattering efficiency of a single Ag rod (80 nm length, 30 nm width, 25 nm height) is plotted as a function of incident angle θ and wavelength. At each wavelength, the angular response is fitted to a $\cos^n\theta$ function, and in (b) the fitted value of n is plotted as a function of incident wavelength.

Figure 4.27: In (a), the scattering efficiency of an arrangement of three Ag rods (from Figure 4.22) is plotted as a function of incident angle θ and wavelength. At each wavelength, the angular response is fitted to a $\cos^n\theta$ function, and in (b) the fitted value of n is plotted as a function of incident wavelength. The dashed line represents the spectral position of the single scattering efficiency maximum which is observed at normal incidence.

Figure 4.28: The scattered electric field distribution for the arrangement of three Ag rods in Figure 4.22 has been simulated using a FEM technique and has been projected onto a spherical surface in the far field. A polar plot of the radiated field in the upper half space is shown for a cross section through the YZ plane. The electric field intensity has been plotted as a function the scattering angle ϕ .

Table 4.1: A summary of the angular response characteristics evaluating the behaviour of the scattering intensity as a function of the incident (θ) and scattering angle (ϕ).

Figure 5.1: An individual dipole i is positioned within an infinite square array of identical dipoles j . The local electric field at the origin is a sum of the incident electric field plus the retarded fields from all other dipoles.

Figure 5.2: When using an FEM approach to simulate infinite arrays of particles, periodic boundary conditions are imposed along x (i) and y (ii) directions.

Figure 5.3: The scattering of an incident plane wave by a small metallic nanoparticle.

Figure 5.4: The electric field distributions at the upper and lower boundaries of the unit cell are used to determine the transmission and reflection coefficients of the structure.

Figure 5.5: A diagram of the experimental apparatus for characterising the optical response of particle arrays using bright-field spectroscopy.

Figure 5.6: SEM images of sections of gold nanoparticle arrays with height 35 nm, periodicity 300 nm and mean diameters ranging from 72 nm to 130 nm.

Figure 5.7: The experimental (i) and simulated (ii) extinction spectra are compared for regular arrays of nanoparticles with 300 nm periodicity and particle diameters ranging from 72 nm to 130 nm. The simulated and experimental resonant wavelengths (iii) and widths (iv) are also compared. The discs are illuminated at normal incidence, and are surrounded by a medium with refractive index $n_r = 1.52$, $n_i = 0.00$.

Figure 5.8: The simulated extinction cross section C_{ext} is shown in (a) for individual discs having height 35 nm and diameters ranging from 72 to 130 nm. In (b), the resonant wavelengths from the single particle simulations are plotted against those determined from the experimental extinction spectra of the arrays. The discs are illuminated at normal incidence, and the surrounding medium has refractive index $n_r = 1.52$, $n_i = 0.00$.

Figure 5.9: In (a) the calculated values of $d\lambda/dn$ from Equation 5.31 are shown for incident wavelengths across the range 300 – 1000 nm, and n_{lreal} varying between 1.5 and 4.5. The dashed arrows represent the wavelengths at which the resonant condition in Equation 5.28 is satisfied. In (b) and (c) the values of ϵ_{metal} at the resonant condition and the LSPR wavelength are plotted as a function of n_{lreal} . The scattering particle is an Au sphere with dimensions $\ll \lambda$, the permittivity values have been obtained using a lossless Drude model ($\omega_p = 1.3 \times 10^{16} \text{ s}^{-1}$).

Figure 5.10: Simulated extinction spectra are shown for arrays of cylindrical Au nanoparticles with height 35 nm, diameter 90 nm and periodicity 300 nm. The refractive index of the glass ($n_r = 1.52$, $n_i = 0.00$) substrate is fixed whilst the refractive index of the superstrate is varied from $n_r = 1.0$ to 2.0.

Figure 5.11: The time-averaged electric field distribution is shown at the resonant frequency for a cross section through the particle, taken perpendicular to the substrate. The arrow above the field profile represents the direction of the incident electric field. The arrow above the field profile represents the polarisation direction of the incident electric field.

Figure 5.12: The simulated extinction spectra are shown for an array of Au cylinders with 35 nm height, 90 nm diameter and 300 nm periodicity embedded in a glass ($n_r = 1.52$, $n_i = 0.00$) substrate, with the superstrate refractive index being varied across the range $n_r = 1.0$ to 2.0.

Figure 5.13: The simulated extinction spectra are shown for an array of Au cylinders with 35 nm height, 90 nm diameter and 300 nm periodicity raised on a glass ($n_r = 1.52$, $n_i = 0.00$) ‘plinth’ of thickness 20 nm, with the superstrate refractive index being varied across the range $n_r = 1.0$ to 2.0.

Figure 5.14: The simulated extinction spectra are shown for arrays of Au cylinders (90 nm diameter, 35 nm height) in which the periodicity of the arrays has been varied from 100 nm to 175 nm in increments of 25 nm. The arrays are illuminated at normal incidence in air on a glass ($n_r = 1.52$, $n_i = 0.00$) substrate.

Figure 5.15: The time-averaged electric field distribution is shown for a cross section taken parallel to the substrate at the resonant frequency for a periodicity of 100 nm. The arrow above the field profile represents the polarisation of the incident electric field along the line of the unit vector \hat{x} .

Figure 5.16: Plan view of a 3×3 array of nanoparticles with radius r and periodicity d . The red arrows represent the direction of the induced dipole moment across the particles, whilst the blue arrows represent the direction of the induced dipole moment between particles. In the left of the figure, the direction of the incident wave vector and the polarisation of the incident electric field are shown.

Figure 5.17: The simulated extinction spectra are shown for arrays of Au cylinders (90 nm diameter, 35 nm height) in which the periodicity of the arrays has been varied from 200 nm to 400 nm in increments of 25 nm. The arrays are illuminated at normal incidence in air on a glass ($n_r = 1.52$, $n_i = 0.00$) substrate.

Figure 5.18: Plan view of a 3×3 array of nanoparticles with radius r and periodicity d . The red arrows represent the direction of the induced dipole moment across the particles,

whilst the blue arrows represent the direction of the radiated electric field. In the left of the figure, the direction of the incident wave vector and the polarisation of the incident electric field are shown.

Figure 5.19: Experimental extinction spectra published by Auguie et al.¹⁶ are shown for square arrays of rectangular Au nanoparticles (35 nm height, 85 nm width, 123 nm length), with periodicities ranging from 480 to 560 nm. The surrounding medium has refractive index $n_r = 1.52$, $n_i = 0.00$. The incident electric field is polarised along the long axis of the particles.

Figure 6.1: A metal film with thickness t is perforated with a square array of cylindrical holes having diameter a and square periodicity d . The diagrams show the structure as viewed from above (left) and in cross section (right).

Figure 6.2: Schematic representations of the dispersion relations are shown for (a) an air - Ag planar interface and (b) an air-Ag shallow monograting. The red lines represent the SPP dispersion curves, and dashed black lines are the diffracted and non-diffracted light lines. It is assumed that the dielectric function of the Ag may be described using a Drude model.

Figure 6.3: The simulated zeroth-order transmittance spectrum is shown for a 200 nm thick Ag film perforated with an array of cylindrical holes with diameter 150 nm and periodicity 600 nm. The sample is illuminated at normal incidence in air, and is situated on a glass ($n_r = 1.52$, $n_i = 0.00$) substrate.

Figure 6.4: The time-averaged electric field distribution is shown for the structure in Figure 6.3. A cross section is taken parallel to the upper metal surface (a) and through the centre of the structure (b). The sample is illuminated at normal incidence with an incident wavelength of 700 nm.

Figure 6.5: The simulated zeroth-order transmittance spectrum is shown for a 200 nm thick Ag film perforated with an array of cylindrical holes with diameter 150 nm and periodicity 900 nm. The sample is illuminated at normal incidence in air, and is situated on a glass ($n_r = 1.52$, $n_i = 0.00$) substrate.

Figure 6.6 reproduced from reference 11: The dark field scattering intensity is shown for nanoholes with diameters ranging from 60 nm to 500 nm, fabricated from a 20 nm thick Au film. The samples are fabricated on a glass ($n_r = 1.52$, $n_i = 0.00$) substrate and are illuminated at normal incidence in air.

Figure 6.7: Experimental transmittance spectra are compared against simulated transmittance and absorbance spectra obtained for 8 μm square arrays of 90 nm diameter holes in a (a) 20 nm thick Au film and (b) 90 nm diameter, 20 nm height cylindrical Au particles with periodicity 200 nm, illuminated at normal incidence in air. The dashed gray curve in both (a) and (b) shows the experimental transmittance spectrum obtained from a 20 nm Au film illuminated at normal incidence in air.

Figure 6.8: Field profiles are shown at the absorbance maximum of the hole and particle array structures. The upper profiles show the instantaneous scattered electric field vector for (a) the hole and (b) the particle arrays, taken at the same instant in phase for each structure. The arrows above (a) and (b) indicate the vector of the incident electric field. The centre plots show the time-averaged scattered electric field profiles for (c) the hole and (d) the particle. In (e) and (f), a line plot has been taken through the centre of the

structures along the dashed line shown in (c) and (d), and the time-averaged electric field magnitude is shown as a function of position across the unit cell.

Figure 6.9: Comparison between experimental and simulated transmission spectra for 90 nm diameter hole ((a) and (c)) and particle ((b) and (d)) arrays with periodicity 200, 225 and 250 nm.

Figure 6.10: The experimental (left) and simulated (right) transmittance spectra are shown for hole arrays with periodicity 250 nm and hole diameters ranging from 70 nm to 100 nm. The arrays are on a glass ($n_r = 1.52$, $n_i = 0.00$) substrate, and are illuminated at normal incidence in air. The dashed gray curves show the experimental and simulated data for a planar Au film with thickness 20 nm.

Figure 6.11: The simulated transmittance spectra are shown for hole arrays with periodicity 200 nm. The solid black line represents the simulated transmittance for arrays of 70 nm diameter cylindrical holes. The dashed and dash-dot lines represent the simulated transmittance of rectangular holes with dimensions 45 nm \times 90 nm illuminated with light having the electric field polarised along the long (dashed) and short (dash-dot) axes. The arrays are on a glass substrate ($n_r = 1.52$, $n_i = 0.00$), and are illuminated at normal incidence in air.

Figure 7.1: Simulated transmittance (T) and absorbance (A) spectra at normal incidence for a planar Ag layer (20 nm thickness) perforated with an infinite square array of 60 nm diameter cylindrical holes with periodicity 150 nm (shown in the inset). The surrounding medium has refractive index ($n_r = 1.52$, $n_i = 0.00$).

Figure 7.2: Simulated transmittance (T) and absorbance (A) spectrum at normal incidence for a single Ag layer (20 nm thickness) and a multi-layer structure consisting of 5 layers of 20 nm Ag separated by 110 nm (A). The surrounding medium has refractive index $n_r = 1.52$, $n_i = 0.00$. The grey line illustrates the resonant frequency for a single layer of 20 nm Ag perforated with holes having diameter 60 nm and periodicity 150 nm. The inset figures (B-E) show the time-averaged electric field magnitude at the resonant frequencies of the FP modes for a cross section taken perpendicular to the stack.

Figure 7.3: Simulated transmittance (T) and absorbance (A) spectra for a planar structure consisting of 5 layers of Ag with thickness 20 nm separated by 110 nm, perforated with an infinite square array of cylindrical holes with 60 nm diameter and 150 nm periodicity. The surrounding medium has refractive index $n_r = 1.52$, $n_i = 0.00$. The solid line corresponds to illumination at normal incidence, the dashed and dotted lines correspond to illumination with TE polarized light at angles 23.5° ($\sin \theta = 0.4$) and 36.9° ($\sin \theta = 0.6$) respectively. The grey line at 545 THz represents the resonant frequency for a single layer of Ag perforated with an identical array of holes (Figure 7.1).

Figure 7.4: Contour plot showing the magnitude of the simulated absorbance as a function of frequency and $\sin \theta$ (where θ is the incident angle) for TE polarized light illuminating the structure in Figure 7.3.

Figure 7.5: The magnitude of the simulated absorbance is plotted as a function of frequency and spacing between two non-perforated (top) and perforated (bottom) Ag layers with thickness 20 nm. The perforated structure consists of an infinite square array of cylindrical holes with diameter 60 nm and periodicity 150 nm. The results are for normal incidence, with surrounding medium $n_r = 1.52$, $n_i = 0.00$. The dashed line

represents the separation of the metal layers in the structures described in Figures 7.2 and 7.3.

Figure 7.6: The simulated transmittance is shown for a structure comprised of 6.5 periods of 20 nm Ag / 120 nm glass ($n_r = 1.52$, $n_i = 0.00$), perforated with an infinite square array of cylindrical holes having periodicity 300 nm and diameters ranging from (a) 20 nm to 100 nm and (b) 20 nm to 45 nm. The structure is illuminated at normal incidence in a glass surrounding medium.

Figure 7.7: (a) The simulated transmittance is shown for a structure comprised of 6.5 periods of 20 nm Ag / 120 nm glass, perforated with an array of cylindrical holes having periodicity 200 nm and diameters ranging from 60 nm to 100 nm. The permittivity of the metal is assumed to be $\epsilon = -32 + 1.8i$ across all wavelengths. (b) The simulated transmittance (T) and absorbance (A) is shown for 60 nm diameter holes. The structures are illuminated at normal incidence in a glass surrounding medium.

Figure 7.8: The simulated transmittance is shown for a 12.5 period structure of 20 nm Ag / 120 nm glass, perforated with an array of square cylindrical holes having periodicity 300 nm and diameters ranging from 40 nm to 100 nm. The structure is illuminated at normal incidence in a glass surrounding medium ($n_r = 1.52$, $n_i = 0.00$).

Figure 7.9: The simulated transmittance (T) and absorbance (A) spectra are shown for (a) a single layer of Ag with thickness 20 nm, perforated with an infinite square array of cylindrical holes with periodicity 225 nm and diameter 90 nm, (b) a multilayer structure comprised of 4.5 periods of planar 20 nm Ag / 140 nm glass layers. The structures are illuminated at normal incidence in a glass surrounding medium.

Figure 7.10: Simulated transmittance (T) and absorbance (A) spectrum at normal incidence for a planar structure consisting of 5 layers of Ag with thickness 20 nm separated by 140 nm, perforated with an infinite square array of cylindrical holes with 90 nm diameter and 225 nm periodicity. The structure is illuminated at normal incidence in a glass surrounding medium.

Figure 8.1: A conventional lens having a positive index of refraction (n_1) is used to form an image of a point source. The arrows represent 'ray' directions.

Figure 8.2: The use of a planar isotropic slab having $n_l = -1 + 0i$ and thickness d for the imaging of a point source. The arrows represent 'ray' directions.

Figure 8.3 reproduced from 9: The experimental sample used by Shelby et al. consisted of copper split ring resonators and copper wire strips on circuit board material. The rings and wires are positioned on opposite sides of the board.

Figure 8.4: The magnetic response of a continuous metallic ring (CMR).

Figure 8.5: Split ring resonators exhibit an LC resonance which is associated with the effective capacitance of the dielectric gap and the effective inductance of the loop which defines the ring.

Figure 8.6: An example of a circular pair of split ring resonators (SRRs), with illustrated dimensions corresponding to those in Equation 8.11.

Figure 8.7 reproduced from reference 4: Diagram of a 21 layer fishnet structure formed from layers of Ag with thickness 30 nm and MgF₂ with thickness 50 nm. The structure has been milled to produce a square array of rectangular holes with dimensions 565 nm × 265 nm, and periodicity 860 nm (a). Simulated and experimental index of refraction data obtained for the ‘fishnet’ structure shown in (b).

Figure 8.8: The structural dimensions of a single layer of the fishnet structure which was analysed by Soukoulis et al.¹⁵ is shown (a), this layer stacked to form periodic structure where the layers are separated by t (b). Assuming the incident electric field is polarized in the direction shown, the equivalent electrical circuit model for this arrangement may be simplified to that shown in (c).

Figure 8.9: An illustration of the surface currents which are formed in the slab and neck regions of the fishnet structure in the uppermost layer of the fishnet structure at the frequency of the magnetic resonance ω_m . In a metamaterial, the directions of the surface currents in adjacent layers are aligned anti-parallel.

Figure 8.10: The real (hollow circles) and imaginary (solid circles) components of the effective refractive index obtained using Equation 8.19 are shown for three homogeneous layers with parameters (a) $\epsilon = 3, \mu = 2$ (b) $\epsilon = -3, \mu = 2$ and (c) $\epsilon = -3, \mu = -2$.

Figure 8.11: The real (hollow circles) and imaginary (solid circles) components of the effective refractive index obtained using Equation 8.20 are shown for three homogeneous layers with parameters (a) $\epsilon = 3, \mu = 2$ (b) $\epsilon = -3, \mu = 2$ and (c) $\epsilon = -3, \mu = -2$.

Figure 8.12: The extraction procedure described in section 8.2 was used to determine the effective refractive index from the simulated transmission and reflection coefficients obtained from finite element simulations (a). This is compared with the published data of Zhang et al.⁴ (b).

Figure 8.13: The time-averaged electric field distribution is shown at the resonant frequency for a single metallic layer of the fishnet structure in Figure 8.7. The arrows above and alongside the field distributions indicate the polarisation direction of the incident electric field.

Figure 8.14: Simulated transmittance (i) and absorbance (ii) spectra are shown for an infinite array of 90 nm diameter holes in a 20 nm thick Ag film with periodicity 225 nm (A), an infinite array of 90 nm diameter, 20 nm height cylindrical Ag particles with periodicity 225 nm (B) and a 20 nm thick continuous Ag film (C). In all simulations the structures were illuminated at normal incidence in vacuum. The inset of (ii) shows the instantaneous scattered electric field vector across the unit cell of the hole and particle array structures. Both profiles are shown at the same instant in phase for radiation incident with frequency 6.25×10^{14} Hz ($\lambda_{\text{vac}} = 480$ nm). The arrows above the field distributions indicate the direction of the incident field vector.

Figure 8.15: The simulated absorbance is plotted as a function of frequency and spacing between two layers of hole (i) and particle (ii) arrays. In both structures the Ag layer thickness is 20 nm, and the cylindrical holes/particles with diameter 90 nm are arranged into regular square arrays with periodicity 225 nm. For 20 nm layer spacing (shown by the dashed line) the absorbance of each arrangement is plotted as a function of frequency as an inset figure. In (a-d), the instantaneous scattered electric field vector has been plotted for a cross section perpendicular to the stack at the resonant frequencies labelled A-D in the

greyscales (i) and (ii). The arrows above the field profiles indicate the direction of the incident electric field vector.

Figure 8.16: The instantaneous charge and field distributions are illustrated for two metallic nanoparticles which interact through the overlap of their resonant electromagnetic fields. Plasmon hybridisation can occur in particles separated by distances which are a few 10s of nm in vacuum, resulting in two coupled LSPRs associated with the anti-symmetric (a) and symmetric (b) distribution of charge across the structure.

Figure 8.17: The effective refractive indices are shown as a function of frequency for the five layer stacked hole array (i) and particle array (ii) structures. In the inset, the real and imaginary parts of the effective permittivity ϵ and permeability μ are shown for the stacked hole array (a,b) and particle array (c,d) structures. The dashed vertical lines in plots (i) and (ii) represent the resonant frequencies of the symmetric (dashed vertical black line) and anti-symmetric (dashed vertical gray line) coupled LSPRs for the equivalent two layer structure studied in Figure 8.15.

Figure A.1: An incident wave \mathbf{k}_i strikes a planar interface between two media with different dielectric properties, giving rise to a reflected wave \mathbf{k}_r , and a refracted wave \mathbf{k}_t .

Figure A.2: Reflection and refraction of an incident plane wave which is polarised perpendicular to the plane of incidence.

Figure A.3: Reflection and refraction of an incident plane wave which is polarised parallel to the plane of incidence.

Figure A.4: The transmission and reflection of light in an arrangement formed from N isotropic layers.

Figure D.1: Labelled photographs of the external connections of the thermal evaporation system are shown (a) and (b). Other types of evaporation chambers may be formed using glass bell-jars (c).

Figure D.2: Labelled photographs of the internal connections of the thermal evaporation system.

Figure D.3: Photographs of two samples (20 nm Ag – 120 nm SiO_x – 20 nm Ag) viewed in reflection at normal incidence are shown. In (a) the vector from the source to the substrate is parallel to the surface normal of the substrate. In (b), the sample has been aligned at an angle of 60° and is rotated at 120 revolutions per minute.